1 2	What is claimed is:
3	1. A method for creating recordable regions and non-recordable regions in a
4	recording layer, the method comprising the steps of:
5	
6	placing a mask over the recording layer, wherein the mask includes a
7	pattern that defines the recordable regions and the non-recordable regions to be
8	created in the recording layer;
9	
10	changing the magnetic properties of portions of the recording layer in
11	order to create recordable regions or non-recordable regions in the recording
12	layer; and
13	
14	removing the mask.
15	
16	2. The season of a single
17	2. The method of claim 1, wherein the recording layer is comprised of a single,
18	dual, or multi-layer recording layer.
19 20	
21	3. The method of claim 2, wherein the step of placing a mask over the recording
22	layer comprises the sub-steps of:
23	
24	forming a mask over the recording layer; and
25	
26	defining a pattern in the mask, wherein the pattern defines the recordable
27	regions and the non-recordable regions to be created in at least one layer in the
28	recording layer.
29	
30	the meals
31	4. The method of claim 3, wherein the step of defining a pattern in the mask
32	comprises the step of defining a pattern in the mask using photolithography.
33	
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5. The method of claim 4, wherein the step of defining a pattern in the mask 1 using photolithography exposes portions of the recording layer. 2 3 4 6. The method of claim 5, wherein the step of changing the magnetic properties 5 of portions of the recording layer comprises the step of exposing the mask and 6 the exposed portions of the recording layer to a plasma, wherein the magnetic 7 properties of at least one layer in the exposed portions of the recording layer are 8 9 changed. 10 11 7. The method of claim 5, further comprising the step of etching away a portion 12 of the recording layer in the exposed portions of the recording layer, wherein 13 grooves are formed in at least one layer within the exposed portions of the 14 15 recording layer. 16 17 8. The method of claim 7, wherein the step of changing the magnetic properties 18 of portions of the recording layer comprises the step of exposing the mask and 19 the exposed portions of the recording layer to a plasma, wherein the magnetic 20 properties of at least one layer in the exposed portions of the recording layer are 21 22 changed. 23 24 9. The method of claim 3, wherein the step of defining a pattern in the mask 25 comprises the step of defining a pattern in the mask using imprint lithography. 26 27

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the recording layer are exposed.

10. The method of claim 9, further comprising the step of removing at least a

portion of the mask after performing imprint lithography, wherein portions of

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1	11. The method of claim 10, wherein the step of changing the magnetic
2	properties of portions of the recording layer comprises the step of exposing the
3	mask and the exposed portions of the recording layer to a plasma, wherein the
4	magnetic properties of at least one layer in the exposed portions of the recording
5	layer are changed.
6	
7	
8	12. The method of claim 10, further comprising the step of etching away a
9	portion of the recording layer in the exposed portions of the recording layer,
10	wherein grooves are formed in at least one layer within the exposed portions of
11	the recording layer.
12	
13	
14	13. The method of claim 12, wherein the step of changing the magnetic
15	properties of portions of the recording layer comprises the step of exposing the
16	mask and the exposed portions of the recording layer to a plasma, wherein the
17	magnetic properties of at least one layer in the exposed portions of the recording
18	layer are changed.
19	
20	
21	14. A system for creating recordable regions and non-recordable regions in a
22	recording layer, the system comprising:
23	
24	means for placing a mask over the recording layer, wherein the mask
25	includes a pattern that defines the recordable regions and the non-recordable
26	regions to be created in the recording layer;
27	the seconding
28	means for changing the magnetic properties of portions of the recording
29	layer in order to create recordable regions or non-recordable regions in the
30	recording layer; and
31	
32	means for removing the mask.
33	

1	15. The system of claim 14, wherein the recording layer is comprised of a single,
2	dual, or multi-layer recording layer.
3	
4	
5	16. The system of claim 15, wherein the means for placing a mask over the
6	recording layer comprises:
7 .	
8	means for forming a mask over the recording layer; and
9	
10	means for defining a pattern in the mask, wherein the pattern defines the
11	recordable regions and the non-recordable regions to be created in at least one
12	layer in the recording layer.
13	
14	and the second s
15	17. The system of claim 16, wherein the means for defining a pattern in the mask
16	exposes portions of the recording layer.
17	
18	18. The system of claim 17, wherein the means for changing the magnetic
19	properties of portions of the recording layer comprises means for exposing the
20 21	mask and the exposed portions of the recording layer to a plasma, wherein the
22	magnetic properties of at least one layer in the exposed portions of the recording
23	layer are changed.
24	
25	
26	19. The system of claim 17, further comprising means for etching away a portion
27	of the recording layer in the exposed portions of the recording layer to form
28	grooves in at least one layer within the exposed portions of the recording layer.
29	
30	
31	20. The system of claim 19, wherein the means for changing the magnetic
32	properties of portions of the recording layer comprises means for exposing the
33	mask and the exposed portions of the recording layer to a plasma, wherein the

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1	magnetic properties of at least one layer in the exposed portions of the recording
2	layer are changed.
3	
4	
5	21. The system of claim 16, wherein the means for defining a pattern in the mask
6	compresses portions of the mask.
7	
8	
9	22. The system of claim 21, further comprising means for removing the
10	compressed portions of the mask in order to expose portions of the recording
11	layer.
12	
13	( ) leave the mean orbita
14	23. The system of claim 22, wherein the means for changing the magnetic
15	properties of portions of the recording layer comprises means for exposing the
16	mask and the exposed portions of the recording layer to a plasma, wherein the
17 12	magnetic properties of at least one layer in the exposed portions of the recording
18	layer are changed.
19	
20	24. The system of claim 22, further comprising means for etching away a portion
21	of the recording layer in the exposed portions of the recording layer to form
22 23	grooves in at least one layer within the exposed portions of the recording layer.
23 24	grooves in at least one layer within the exposed positions of
2 <del>4</del> 25	
26	25. The system of claim 24, wherein the means for changing the magnetic
27	properties of portions of the recording layer comprises means for exposing the
28	mask and the exposed portions of the recording layer to a plasma, wherein the
<b>2</b> 9	magnetic properties of at least one layer in the exposed portions of the recording
30	layer are changed.
31	
32	
33	26. A magnetic recording media for a storage device, comprising:

1	non-recordable regions in the magnetic recording media; and
2	
3	recordable regions in the magnetic recording media, wherein the
4	coercivity of the non-recordable regions differ from the coercivity of the
5	recordable regions.
6	
7	
8	27. A storage system, comprising:
9 .	
10	a storage disk having recordable and non-recordable regions, wherein the
11	recordable and non-recordable regions are defined by different magnetic
12	properties in a recording layer on the storage disk; and
13	
14	means for reading from, and writing to, the recordable regions on the
15	storage disk.